# Build in Biasing Circuit MOS FET IC UHF/VHF RF Amplifier

## HITACHI

ADE-208-606C (Z) 4th. Edition August 1998

#### **Features**

- Build in Biasing Circuit; To reduce using parts cost & PC board space.
- · High gain;

(PG = 29 dB typ. at f = 200 MHz)

• Low noise characteristics;

(NF = 1.2 dB typ. at f = 200 MHz)

• Wide supply voltage range;

Applicable with 5V to 9V supply voltage.

• Withstanding to ESD;

Build in ESD absorbing diode. Withstand up to 200V at C=200pF, Rs=0 conditions.

• Provide mini mold packages; CMPAK-4(SOT-343mod)

#### **Outline**

#### CMPAK-4



- 1. Source
- 2. Gate 1
- 3 Gate2
- 4. Drain

Notes: 1 Marking is "DW-".

2. BB304C is individual type number of HITACHI BBFET.



## Absolute Maximum Ratings ( $Ta = 25^{\circ}C$ )

Item	Symbol	Ratings	Unit		
Drain to source voltage	V <sub>DS</sub>	12	V		
Gate1 to source voltage	$V_{\sf G1S}$	+10 -0	V	V	
Gate2 to source voltage	$V_{\rm G2S}$	±10	V		
Drain current	I <sub>D</sub>	25	mA		
Channel power dissipation	Pch	100	mW		
Channel temperature	nel temperature Tch		°C		
Storage temperature	Tstg	-55 to +150	°C		

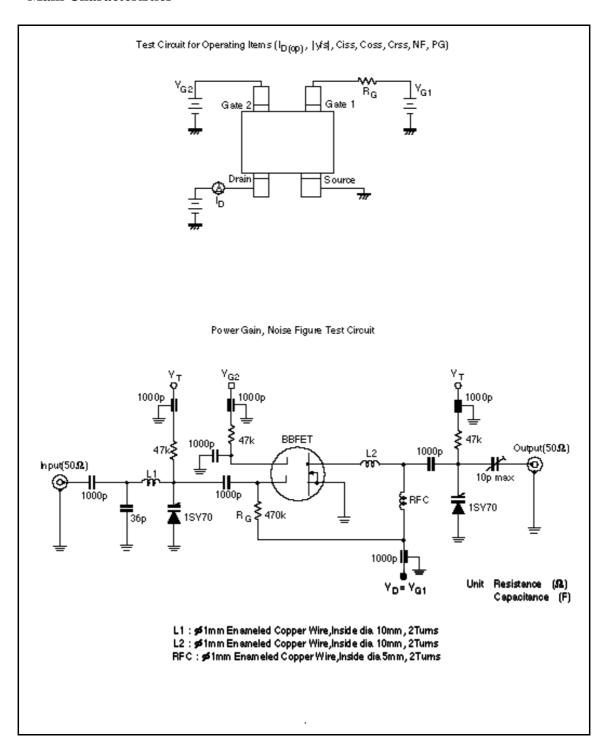
## **Electrical Characteristics** ( $Ta = 25^{\circ}C$ )

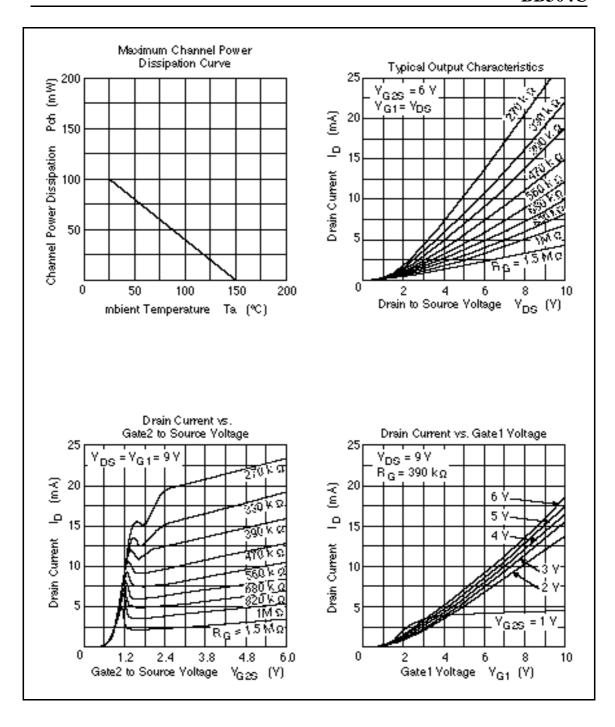
Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	12	_	_	V	$I_D = 200 \mu A, V_{G1S} = V_{G2S} = 0$
Gate1 to source breakdown voltage	$V_{(BR)G1SS}$	+10	_	_	V	$I_{G1} = +10\mu A, V_{G2S} = V_{DS} = 0$
Gate2 to source breakdown voltage	$V_{(BR)G2SS}$	±10	_	_	V	$I_{G2} = +10\mu A, V_{G1S} = V_{DS} = 0$
Gate1 to source cutoff current	I <sub>G1SS</sub>	_	_	+100	nA	$V_{G1S} = +9V, V_{G2S} = V_{DS} = 0$
Gate2 to source cutoff current	I <sub>G2SS</sub>	_	_	±100	nA	$V_{G2S} = +9V, V_{G1S} = V_{DS} = 0$
Gate1 to source cutoff voltage	$V_{\text{G1S(off)}}$	0.4	_	1.0	V	$V_{DS} = 5V, V_{G2S} = 4V$ $I_{D} = 100\mu A$
Gate2 to source cutoff voltage	$V_{\text{G2S(off)}}$	0.5	_	1.0	V	$V_{DS} = 5V, V_{G1S} = 5V$ $I_{D} = 100\mu A$

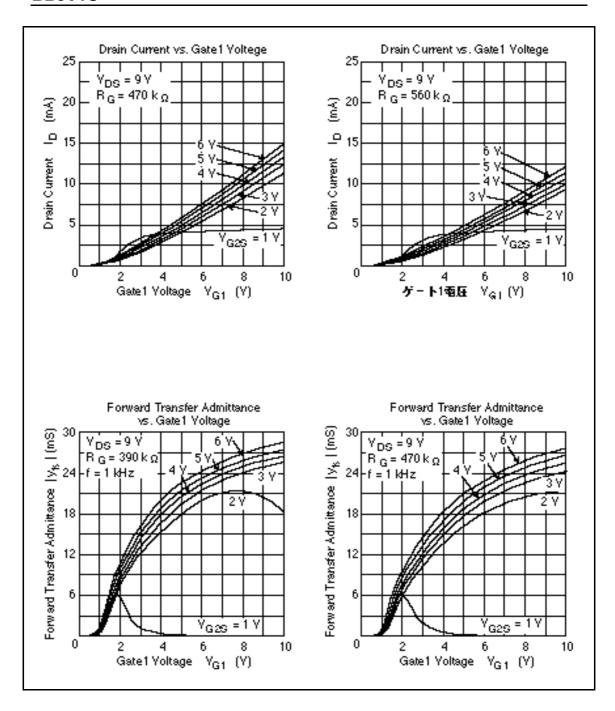
## **Electrical Characteristics** ( $Ta = 25^{\circ}C$ )

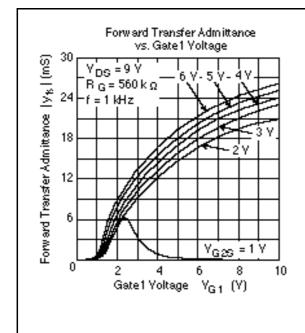
Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Input capacitance	C <sub>iss</sub>	2.3	2.8	3.6	pF	$V_{DS} = 5V, V_{G1} = 5V, V_{G2S} = 4V$
Output capacitance	C <sub>oss</sub>	0.9	1.3	2.0	pF	$R_{\rm G} = 180 k$ , $f = 1 MHz$
Reverse transfer capacitance	C <sub>rss</sub>	0.003	0.02	0.05	pF	_
Drain current	I <sub>D(op)</sub> 1	9	14	19	mA	$V_{DS} = 5V, V_{G1} = 5V, V_{G2S} = 4V$ $R_{G} = 180k$
	I <sub>D(op)</sub> 2	_	13	_	mA	$V_{DS} = 9V, V_{G1} = 9V, V_{G2S} = 6V$ $R_{G} = 470k$
Forward transfer admittance	y <sub>fs</sub>  1	22	27	34	mS	$V_{DS} = 5V, V_{G1} = 5V, V_{G2S} = 4V$ $R_{G} = 180k, f = 1kHz$
	y <sub>fs</sub>  2	_	27	_	mS	$V_{DS} = 9V, V_{G1} = 9V, V_{G2S} = 6V$ $R_{G} = 470k, f = 1kHz$
Power gain	PG1	24	29	32	dB	$V_{DS} = 5V, V_{G1} = 5V, V_{G2S} = 4V$ $R_{G} = 180k, f = 200MHz$
	PG2	_	29	_	dB	$V_{DS} = 9V, V_{G1} = 9V, V_{G2S} = 6V$ $R_{G} = 470k, f = 200MHz$
Noise figure	NF1	_	1.2	1.9	dB	$V_{DS} = 5V, V_{G1} = 5V, V_{G2S} = 4V$ $R_{G} = 180k, f = 200MHz$
	NF2	_	1.2	_	dB	$V_{DS} = 9V, V_{G1} = 9V, V_{G2S} = 6V$ $R_{G} = 470k, f = 200MHz$

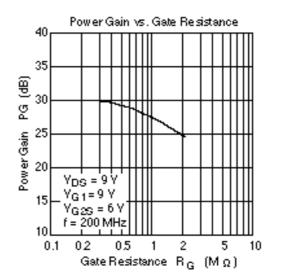
#### **Main Characteristics**

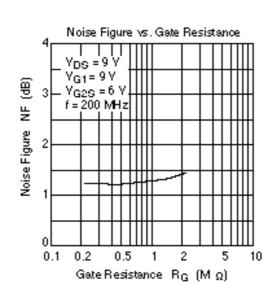


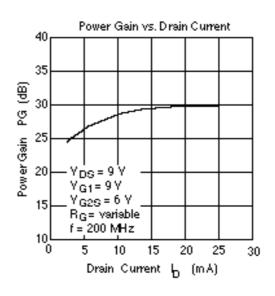


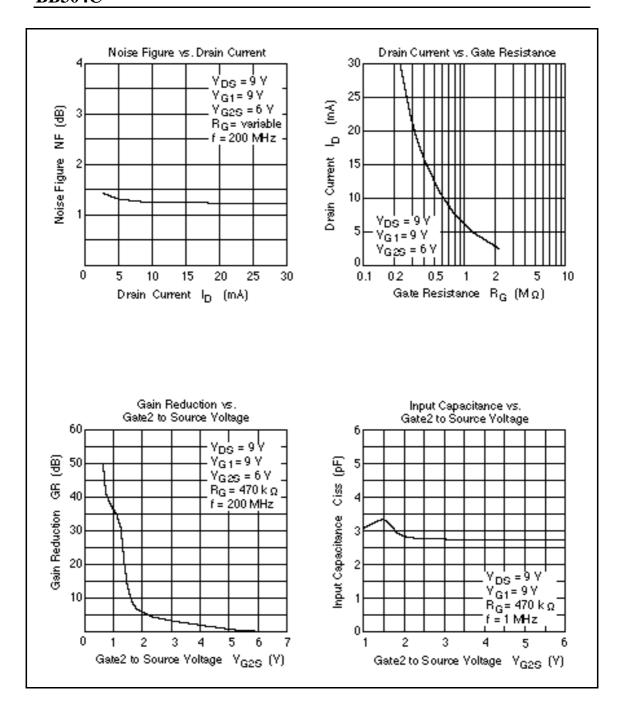


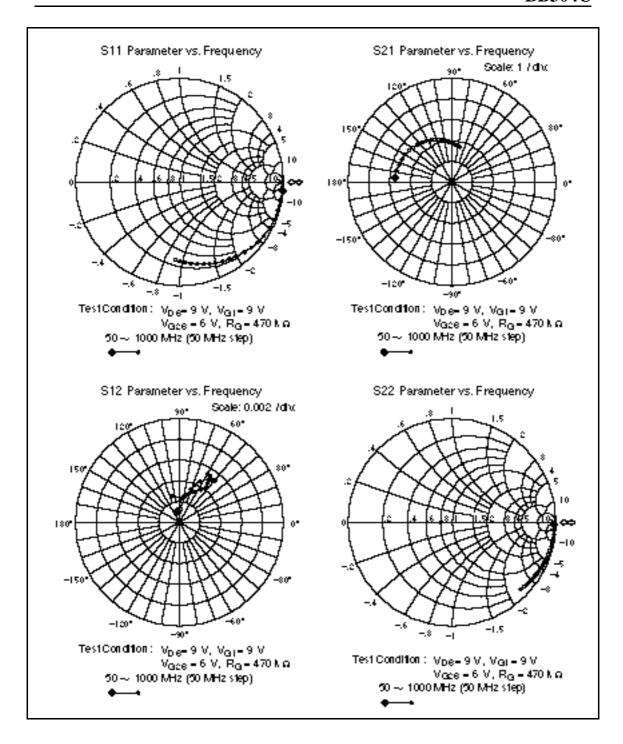










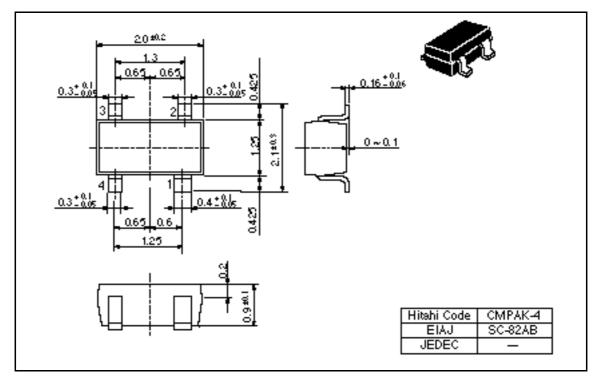


 $\textbf{Sparameter} \; (V_{DS} = V_{G1} = 9V, \; V_{G2S} = 6V, \; R_G = 470k \quad , \; Zo = 50 \quad )$ 

	S11		S21		S12		S22	
f (MHz)	MAG	ANG	MAG	ANG	MAG	ANG	MAG	ANG
50	0.996	-5.3	2.74	174.0	0.00096	98.6	0.985	-1.9
100	0.993	-10.9	2.73	168.0	0.00130	84.4	0.991	-4.5
150	0.987	-16.6	2.68	162.3	0.00203	83.6	0.990	-6.5
200	0.978	-21.9	2.66	156.3	0.00285	72.3	0.988	-9.4
250	0.972	-27.4	2.63	150.4	0.00335	69.7	0.985	-11.6
300	0.954	-33.2	2.57	144.3	0.00385	68.3	0.982	-14.0
350	0.943	-38.2	2.50	138.7	0.00455	63.2	0.979	-16.2
400	0.925	-43.2	2.43	133.3	0.00488	55.4	0.975	-18.4
450	0.910	-48.0	2.37	128.0	0.00526	59.8	0.971	-21.0
500	0.893	-52.5	2.30	122.6	0.00522	56.1	0.967	-23.0
550	0.880	-57.4	2.24	117.5	0.00498	53.2	0.962	-25.2
600	0.861	-62.1	2.17	112.7	0.00512	49.1	0.957	-27.3
650	0.847	-66.1	2.10	108.1	0.00497	53.4	0.952	-29.4
700	0.829	-69.9	2.02	103.6	0.00455	53.6	0.947	-31.6
750	0.816	-74.1	1.96	99.1	0.00418	51.6	0.943	-33.7
800	0.804	-78.2	1.91	94.8	0.00372	55.7	0.937	-35.8
850	0.791	-82.4	1.85	80.4	0.00329	62.4	0.933	-38.0
900	0.779	-86.1	1.79	86.3	0.00275	73.0	0.928	-40.0
950	0.764	-89.5	1.73	82.2	0.00233	82.4	0.921	-42.1
1000	0.753	-92.4	1.68	78.3	0.00258	105.1	0.918	-44.2

## **Package Dimensions**

Unit: mm



#### **Cautions**

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